Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1 - 13 (canceled)

14 (currently amended): An extruded base for an imaging element~~article~~ comprising a matrix polymer and an intercalated clay comprising clay intercalated with polyether block polyamide copolymer~~, wherein said article comprises a base for an imaging member~~.

15 (currently amended): The extruded base ~~article~~ of claim 14 wherein said matrix polymer comprises polyolefin.

16 (currently amended): The extruded base ~~article~~ of claim 14 wherein said matrix polymer comprises poly(propylene).

17 (currently amended): The extruded base ~~article~~ of claim 14 wherein said matrix polymer comprises polyester.

18 (currently amended): The extruded base ~~article~~ of claim 17 wherein said polyester comprises polyethylene terephthalate.

19 (currently amended): The extruded base ~~article~~ of claim 17 wherein said polyester comprises crystalline polyester.

20 (currently amended): The extruded base ~~article~~ of claim 17 wherein said polyester comprises amorphous polyester.

21 (currently amended): The extruded base ~~article~~ of claim 14 wherein said matrix polymer is selected from the group consisting of polyamides, polyimides, and polystyrene.

22 (currently amended): The extruded base ~~article~~ of claim 14 wherein said article further comprises compatibilizer.

23 (currently amended): The extruded base ~~article~~ of claim 22 wherein said compatibilizer comprises polyolefins.

24 (currently amended): The extruded base ~~article~~ of claim 14 wherein said article has a surface resistivity of less than 10^{13} ohms per square.

25 (currently amended): The extruded base ~~article~~ of claim 24 wherein said surface resistivity is between 10^{8} and 10^{12} ohms per square.

26 (currently amended): The extruded base ~~article~~ of claim 14 wherein the Young's modulus of the said copolymer and matrix polymer is enhanced by at least 10%.

27 (currently amended): The extruded base ~~article~~ of claim 14 wherein the Young's modulus of the said copolymer and matrix polymer is enhanced by at least 20%.

28 (currently amended): The extruded base ~~article~~ of claim 27 wherein said matrix polymer comprises polyolefin and said polyolefin comprises between 20 and 99.9 % by weight of said article.

29 (currently amended): The extruded base ~~article~~ of claim 14 wherein said clay comprises smectite clay.

30 (currently amended): The extruded base ~~article~~ of claim 14 wherein said clay comprises synthetic smectite clay.

31 (currently amended): The extruded base ~~article~~ of claim 14 wherein the ratio by weight of clay to copolymer is between 1:99 and 99:1.

32 (currently amended): The extruded base ~~article~~ of claim 14 wherein the polyether to polyamide molecular weight ratio is between 5:95 and 95:5.

33 (currently amended): The extruded base ~~article~~ of claim 14 wherein said copolymer comprises blocks selected from the group consisting of polyamide 6, polyamide 12, polyethylene oxide, polyethylene glycol, polytetramethylene oxide, and polytetramethylene glycol.

34 (currently amended): The extruded base ~~article~~ of claim 33 wherein in said polyether block comprises a structure

$$(\text{--}OC_x\ H_{2x}\ \text{--})_n$$

wherein x is from 2 to about 8, wherein the alkyl group is straight or branched, and

wherein n is from 2 to about 1000.

35 (currently amended): The extruded base ~~article~~ of claim 14 wherein said imaging member comprises a base for a photographic member.

36 (canceled):

37 (currently amended): An extruded base ~~article~~ comprising polyether block polyamide copolymer and intercalated clay, wherein said article comprises a base for an imaging member.

38 (currently amended): The extruded base ~~article~~ of claim 37 wherein said article has a surface resistivity of less than 10^{13} ohms per square.

39 (currently amended): The extruded base ~~article~~ of claim 37 wherein the Young's modulus of the said copolymer is enhanced by at least 10%.

40 (currently amended): The extruded base ~~article~~ of claim 37 wherein the Young's modulus of the said copolymer is enhanced by at least 20%.

41 (currently amended): The extruded base ~~article~~ of claim 37 wherein said clay comprises smectite clay.

42 (currently amended): The extruded base ~~article~~ of claim 37 wherein said clay comprises synthetic smectite clay.

43 (currently amended): The extruded base ~~article~~ of claim 37 wherein the ratio by weight of clay to copolymer is between 1:99 and 99:1.

44 (currently amended): The extruded base ~~article~~ of claim 37 wherein the polyether to polyamide molecular weight ratio is between 5:95 and 95:5.

45 (currently amended): The extruded base ~~article~~ of claim 37 wherein said copolymer comprises blocks selected from the group consisting of polyamide 6, polyamide 12, polyethylene oxide, polyethylene glycol, polytetramethylene oxide, and polytetramethylene glycol.

46 (currently amended): The extruded base ~~article~~ of claim 37 wherein said imaging member comprises a base for a photographic member.

47 (canceled):

48 (canceled):

49 (currently amended): The extruded base ~~article~~ of claim 14 wherein in said polyamide block comprises the recurring unit represented by the general formula:

$$--NHCOR^1COHNR^2--$$

wherein R^1 is an alkylene group of at least 2 carbon atoms or~~and~~ arylene having at least 6 carbon atoms; and

R^2 is selected from R^1 and aryl groups.

50 (currently amended): The extruded base ~~article~~ of claim 37 wherein in said polyether block comprises a structure

$$(\text{--}OC_x\ H_{2x}\ \text{--})_n$$

wherein x is from 2 to about 8, wherein the alkyl group is straight or branched, and

wherein n is from 2 to about 1000.

51 (currently amended): The extruded base ~~article~~ of claim 37 wherein in said polyamide block comprises the recurring unit represented by the general formula:

$$\text{--}NHCOR^1COHNR^2\ \text{--}$$

wherein R^1 is an alkylene group of at least 2 carbon atoms or~~and~~ arylene having at least 6 carbon atoms; and

R^2 is selected from R^1 and aryl groups.

52 (canceled)

53 (canceled)